



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Toshiyuki OGATA, et al.

Application No. 09/922,723

Group Art Unit: 1752

Confirmation No.: 1261

Examiner: To be assigned

Filed: August 7, 2001

For: POSITIVE RESIST COMPOSITION AND BASE MATERIAL CARRYING LAYER OF  
THE POSITIVE RESIST COMPOSITION

RECEIVED  
OCT 17 2001  
TC 1700  
#4  
D.G.  
11-28-01

INFORMATION DISCLOSURE STATEMENT  
UNDER 37 C.F.R. §§ 1.97 and 1.98

Commissioner for Patents  
Washington, D.C. 20231

Sir:

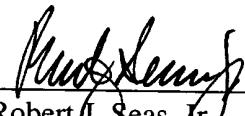
Pursuant to Applicants' duty of voluntary disclosure under Rule 56, and for the  
Examiner's convenience, we submit herewith:

- a) a form PTO-1449 listing three (3) references of potential relevancy; and,
- b) a complete copy of each reference.

No certification or fee is required.

Regarding the concise explanation of relevancy requirement for foreign language  
documents, an English language abstract is enclosed for each reference.

Respectfully submitted,

  
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Robert L. Seas, Jr.  
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Date: October 16, 2001